

## Supporting Information

Title: Ultrafast, One-Step, Salt-Solution-Based Acoustic Synthesis of  $\text{Ti}_3\text{C}_2$  MXene

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## Supplementary Text

### Estimation of number of devices required for synthesis of 1 kg MXene per week.

Ti<sub>3</sub>AlC<sub>2</sub> MAX Phase: 100 mg in 20 ml solution

MXene output: ~ 12 mg

Number of devices: 1

Flow rate: 0.2ml/min (*i.e.* 20 ml ~ 100 minutes)

The data above implies 12 mg MXene in 100 minutes for one device, which equals 0.173 g in 1 day.

For 830 devices, we will then produce 143.5 g /day. In a week that equals to 1 kg of MXene.

### The level of safety of the SAW- and LiF-based method for producing Ti<sub>3</sub>C<sub>2</sub>T<sub>z</sub> from Ti<sub>3</sub>AlC<sub>2</sub>:

The input and the output of the technique are acid-free. The input comprises LiF (salt), MAX phase (Ti<sub>3</sub>AlC<sub>2</sub>) and water. The output comprises MXene (Ti<sub>3</sub>C<sub>2</sub>T<sub>z</sub>), unetched MAX phase (Ti<sub>3</sub>AlC<sub>2</sub>), LiF residual particles, and water. During the process “*in situ* HF” is created with a maximum concentration of 0.1%, which is at the lower limit for the least hazardous HF concentration according to <https://www.prevent.se/amnesomrade/kemiska-risker/>. The hazards and safety precautions are found below. This amount of “*in situ* HF” is formed during the process in an enclosed container, and when the process is stopped, the F ions are depleted. This is because the amount of F<sup>-</sup> ions produced from the dissolution of LiF in water is not sufficient to convert all Al in the MAX phase to AlF<sub>3</sub> hydrates. Therefore, the outcome of the process is acid free.

## Fluoric acid (aqueous)

### CLP-Classification

H300	Acute Tox. 2 - Acute toxicity
H310	Acute Tox. 1 - Acute toxicity
H314	Skin Corr. 1A - Skin corrosion/irritation
H318	Eye Dam. 1 - Serious eye damage/eye irritation
H318	Eye Dam. 1 - Serious eye damage/eye irritation
H330	Acute Tox. 2 - Acute toxicity

### CLP-Marking

#### Concentration range

0.1% - 0.25%

### Hazard pictograms



### Signal word

WARNING

### Hazard statements

H319	Causes serious eye irritation
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### Precautionary statement - Prevention

P264	Wash ... thoroughly after handling.
P280	Wear protective gloves/protective clothing/eye protection/face protection.

### Precautionary statement - Response

P337+P313	If eye irritation persists: Get medical advice/attention.
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### Remarks

Harmonised classification according to (EG) nr 1272/2008.

**Figure S1:** Safety data sheet for 0.1-0.25 % conc. HF.

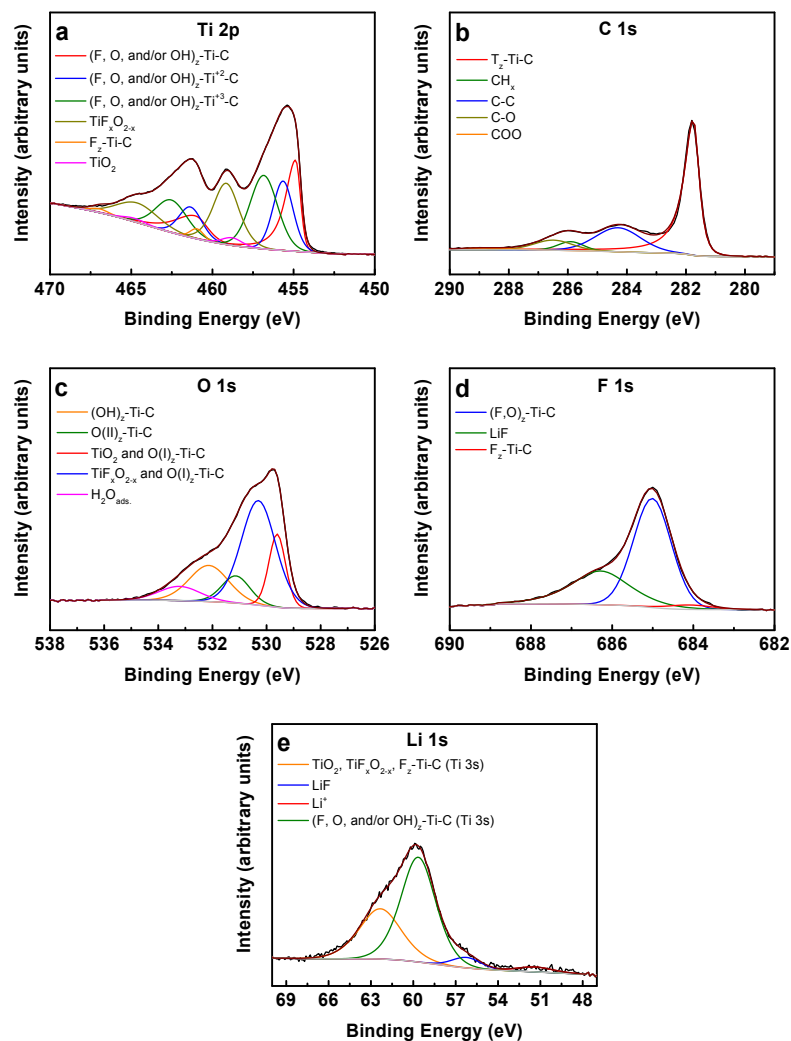
### Electrochemical Characterization

Figure S4A presents the cyclic voltammogram profile of  $\text{Ti}_3\text{C}_2\text{T}_z$  collected at  $10 \text{ mV s}^{-1}$  in  $1 \text{ M H}_2\text{SO}_4$  electrolyte. Redox peaks can be identified in the CV profile, with both the oxidation peak and the reduction peak located at  $-0.55 \text{ V}$  showing a highly reversible redox reaction. The open circuit voltage (OCV) was stable at  $0.3 \text{ V}$ . The electrodes used for current collection were glassy carbon, having the ability to suppress the hydrogen evolution reaction, with a wide voltage window of  $0.9 \text{ V}$ . The charge storage mechanisms were studied for the  $\text{Ti}_3\text{C}_2\text{T}_z$  electrode through the CV currents collected at different scan rates, a method reported by Wang *et al.*,<sup>23]</sup> that relates the sweep rates and collected current through the  $i = av^b$  formula, in which the  $b$  value is the slope of the  $\log I$  versus  $\log V$  curve. The storage mechanism is diffusion limited if the  $b$  value is  $\sim 0.5$ , while a capacitive storage mechanism is dominant for a  $b$  value of  $1$ . As shown in Fig. S4A, the  $b$  value is close to  $1$  at different scan rates. Figure S4B shows the Nyquist plot, and the observed straight vertical line in the low frequency region is an indication of pure capacitive behavior for the  $\text{Ti}_3\text{C}_2\text{T}_z$  electrode. From the real axis, the equivalent series resistance (ESR) was  $0.08 \Omega \cdot \text{cm}^2$ . Both electrochemical stability and Coulombic efficiency are decisive factors in the evaluation of any energy storage system. By charging and discharging at a current density of  $10 \text{ A g}^{-1}$  for  $10,000$  cycles, the  $\text{Ti}_3\text{C}_2\text{T}_z$  electrode (three-electrodes system) shows  $92\%$  stability and almost  $100\%$  Columbic efficiency (see Figure S4C), demonstrating outstanding long-life electrochemical stability. In the inset, the symmetric shape of the galvanostatic cycling profile is shown, being maintained after  $10,000$  cycles with only a very insignificant reduction in the capacitance. The CV profiles for a  $2 \mu\text{m}$  film (see Fig. S4D) shows that the MXene charging mechanism is more or less maintained for different scan rates. Furthermore, a high-rate performance was observed. Figure S2E represents the method to calculate the  $b$ -value fitting parameter. The symmetrical behavior in the charge-discharge curves at various current densities, shown in Fig. S4F, confirms the high electrochemical reversibility.

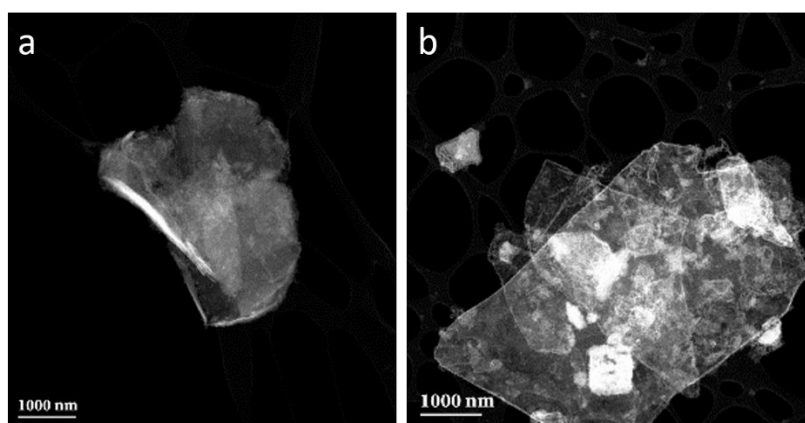
For the sake of comparison between the produced MXene from the mild conventional etching ( $F_1$ ) and the SAW technique ( $F_2$ ), we prepare  $Ti_3C_2$  MXene by mild conventional etching (12 M HCl and 5M LiF) and filter a film from an unwashed colloidal solution. This allows a more direct comparison to the results from the film originating from the SAW technique.

The XRD patterns in Fig S6a show that both the  $F_1$  and  $F_2$  films contain residual LiF particles. The electrochemical performance of a washed and unwashed film from conventional mild synthesis is 230 and 210  $Fg^{-1}$ , respectively, *i.e.*, about 8 % reduction when washing is omitted. This is close to within the experimental error range.

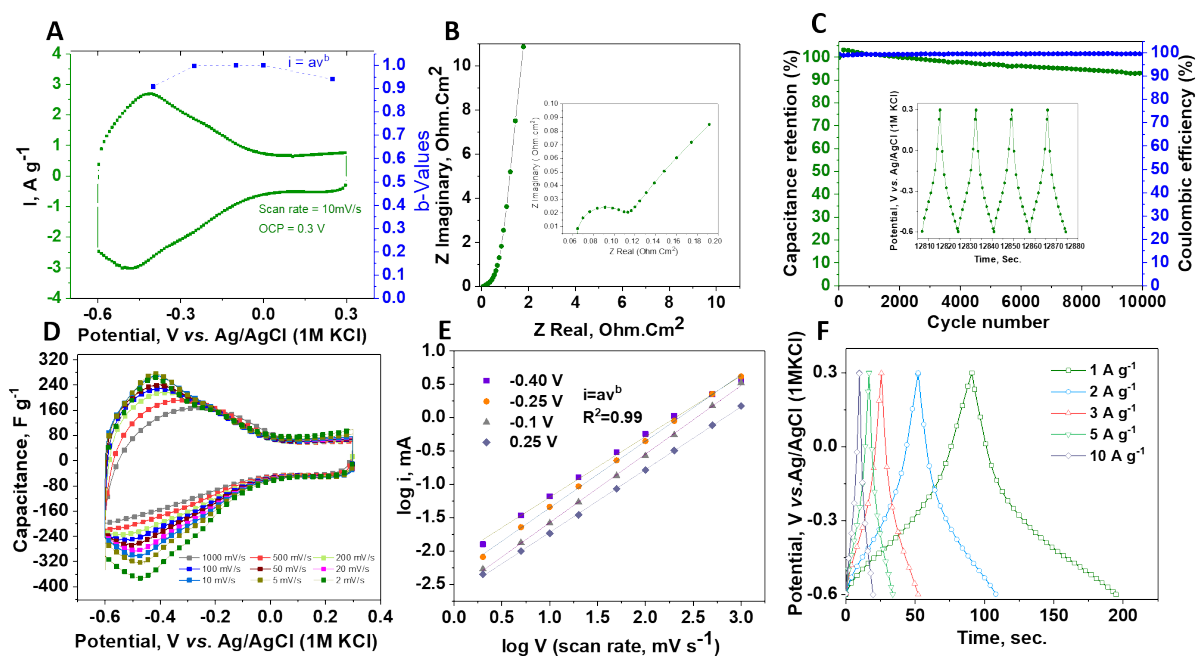
A comparison between the  $F_1$  and  $F_2$  films is shown in Figure S6b indicating that the film originating from the SAW technique has about 14% lower capacitance at low scan rates compared to the conventionally derived material, though this difference decreases with increasing scan rate. It should be stressed that the initial work on SAW-facilitated MXene is produced for proof of concept, and the slight difference may at least in part be due to changes in the electrode materials (density, thickness, sheet size, *etc.*)



**Figure S2.** XPS spectra with curve-fitting for Ti<sub>3</sub>C<sub>2</sub>T<sub>z</sub> of the following regions: (A) Ti 2p, (B) C 1s, (C) O 1s, (D) F 1s and (E) Li 1s. Details for the labeled species are tabulated in Table S1.

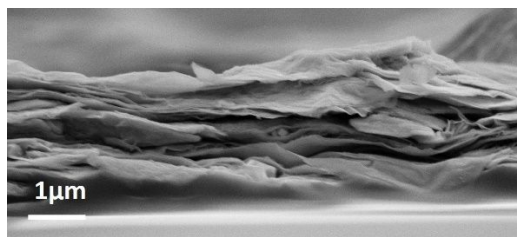


**Figure S3.** TEM analysis showing as prepared  $\text{Ti}_3\text{C}_2$  single MXene sheets ( $> 1 \mu\text{m}$ ).

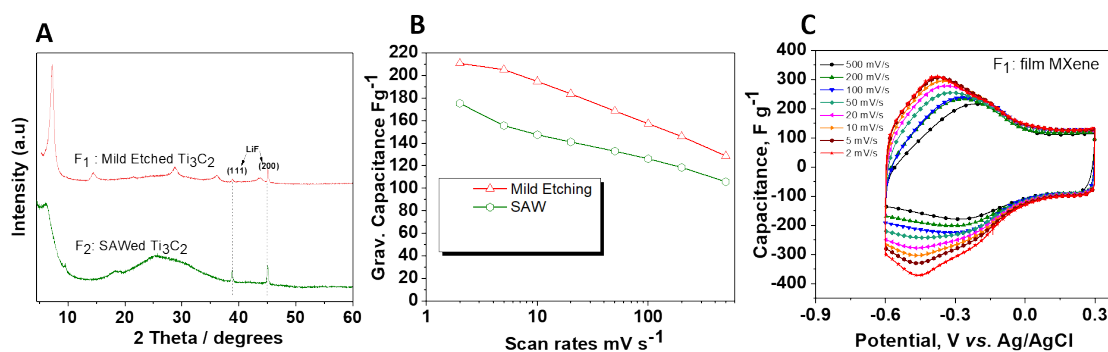


**Figure S4.** Electrochemical behaviour for a freestanding  $\text{Ti}_3\text{C}_2\text{T}_z$  MXene film in 1 M  $\text{H}_2\text{SO}_4$  vs. Ag/AgCl in 1M KCl. **(A)** Cyclic voltammetry profile measured at 10  $\text{mV S}^{-1}$ . The b-values (blue symbols) are the slope of the logarithmic anodic current peaks against the logarithmic scan rates (2–1000  $\text{mV s}^{-1}$ ). **(B)** Nyquist plots of MXene collected *via* EIS; the inset shows the values in the low frequency region. **(C)** Capacitance retention and Coulombic efficiency test for a 2  $\mu\text{m}$  film electrode; the inset shows the galvanostatic charge/discharge at 10  $\text{A g}^{-1}$ . **(D)** Normalized cyclic voltammetry profile measured at 2–1000  $\text{mV S}^{-1}$  for the 2  $\mu\text{m}$  film. **(E)** Logarithmic anodic current peaks vs. logarithmic scan rates (2–1000  $\text{mV S}^{-1}$ ) at different voltage windows for the 2  $\mu\text{m}$  electrode. **(F)** Galvanostatic cycling at 1, 2, 3, 5 and 10  $\text{A g}^{-1}$ .

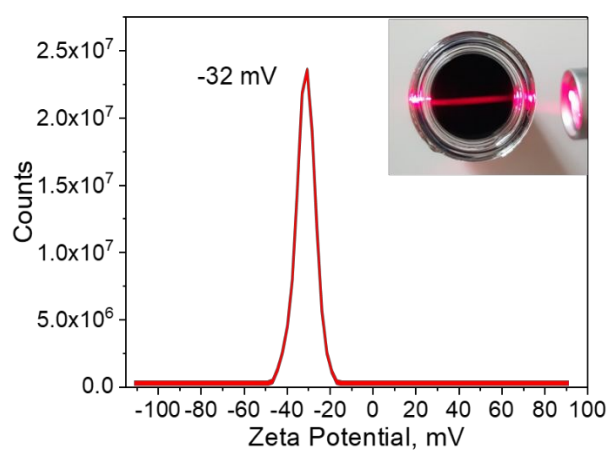




**Figure S5.** SEM image showing a cross-section of a  $\text{Ti}_3\text{C}_2\text{T}_z$  MXene film of approximately 2  $\mu\text{m}$  thickness used for electrochemical characterization.



**Figure S6.** (A) XRD pattern for a free-standing film of  $\text{Ti}_3\text{C}_2\text{T}_z$  MXene from Mild etching (F1) and from the SAW techniques (F2), without HCl and LiCl treatment to remove LiF residuals. (B) Gravimetric capacitance of  $\text{Ti}_3\text{C}_2\text{T}_z$  MXene films in 1 M  $\text{H}_2\text{SO}_4$  vs. Ag/AgCl in 1M KCl. (C) Cyclic voltammetry of the F<sub>1</sub> film at various scan rates.



**Figure S7.** Zeta potential measurements of  $\text{Ti}_3\text{C}_2\text{T}_x$  MXene sheets produced by the SAW technique, and a digital photo (figure inset) of the MXene colloids clearly showing a discernible Tyndall scattering effect.

**Table S1.** Summary of global atomic percentages obtained from the high resolution XPS spectra of the following regions: Ti 2p, C 1s, O 1s, F 1s, Al 2p and Cl 2p of a  $\text{Ti}_3\text{C}_2\text{T}_z$  freestanding film.

Elements	Ti at. %	C at. %	O at.%	F at. %	Cl at. %	Li at. %	Al at. %
$\text{Ti}_3\text{C}_2\text{T}_z$	31.5±0.3	28.4±0.5	19.5±0.8	10.9±0.2	1.5±0.1	7.9±0.2	0.3±0.2

**Table S2.** XPS peak fitting results of  $\text{Ti}_3\text{C}_2\text{T}_z$  for the following regions: Ti 2p, C 1s, O 1s, F 1s and Li 1s.

Region	BE [eV] <sup>a</sup>	FWHM [eV] <sup>a</sup>	Fraction	Assigned to	Reference
Ti 2p	454.9 (461.1)	0.7 (1.3)	0.22	(F, OH, and/or O)-Ti-C	(1,2,3)
	455.7 (461.3)	1.4 (2.1)	0.20	(F, OH, and/or O)-Ti <sup>2+</sup> -C	
	456.8 (462.5)	2.0 (2.3)	0.29	(F, OH, and/or O)-Ti <sup>3+</sup> -C	
	458.7 (464.7)	1.5 (3.7)	0.03	TiO <sub>2</sub>	
	459.2 (464.7)	1.8 (2.6)	0.22	TiF <sub>x</sub> O <sub>2-x</sub>	
	461.0 (467.0)	1.7 (2.7)	0.04	F <sub>z</sub> -Ti-C	
C 1s	281.8	0.5	0.61	T <sub>z</sub> -Ti-C	(1,2,3)
	284.3	1.8	0.24	C-C	
	285.9	1.0	0.05	CH <sub>x</sub>	
	286.5	1.5	0.08	C-O	
	288.8	2.0	0.02	COO	
O 1s	529.6	0.7	0.16	TiO <sub>2</sub> and O(I) <sub>z</sub> -Ti-C	(1,2,3)
	530.3	1.5	0.47	TiF <sub>x</sub> O <sub>2-x</sub> and O(I) <sub>z</sub> -Ti-C	
	531.1	1.2	0.10	O(II) <sub>z</sub> -Ti-C/OR <sup>b</sup>	
	532.1	1.7	0.19	(OH) <sub>z</sub> -Ti-C/OR <sup>b</sup>	
	533.2	1.8	0.08	H <sub>2</sub> O <sub>ads</sub> /OR <sup>b</sup>	
F 1s	684.1	1.3	0.03	(F) <sub>z</sub> -Ti-C	(1,2,3)
	685.0	1.1	0.64	(F, O) <sub>z</sub> -Ti-C	(1,2,3)
	686.3	1.7	0.33	LiF	(4,5)

Li 1s				Li <sup>+</sup> (Li 1s)	(4,5)
	51.4	3.0	0.37	LiF (Li 1s)	
	56.2	2.4	0.63	(F, O, and/or OH) <sub>z</sub> -Ti-C	
	59.6	2.9		(Ti 3s)	
	62.3	3.5		TiO <sub>2</sub> , TiF <sub>x</sub> O <sub>2-x</sub> , F <sub>z</sub> -Ti-C (Ti 3s)	

<sup>a</sup> Values in parentheses correspond to the 2p<sub>1/2</sub> component.

<sup>b</sup> OR denotes the organic compounds that are present due to atmospheric surface contamination.

Note: the TiO<sub>2</sub> and TiF<sub>x</sub>O<sub>2-x</sub> species are formed during exposure of the sample to the ambient during transfer to the XPS (the formation of such oxides is common for MXene washing and/or exposure to the ambient).<sup>5</sup>

**Table S3.** List of various species assigned by XPS analysis.

Species Names	What does it belong to
(F, OH, and/or O)-Ti-C, (F, OH, and/or O)-Ti <sup>2+</sup> -C and (F, OH, and/or O)-Ti <sup>3+</sup> -C	Ti belonging to MXene compound with various oxidation states and terminated by F, O and/or OH surface groups
TiO <sub>2</sub> , and TiF <sub>x</sub> O <sub>2-x</sub>	Surface oxides and oxyfluorides usually found on the surface of the sample due to its contact with oxygen from the air
F <sub>x</sub> -Ti-C	MXene terminated by F surface group without the influence of other adsorbates or surface groups
T <sub>z</sub> -Ti-C	C belonging to the MXene compound, where the MXene is terminated by F, O and/or OH surface groups
C-C, CH <sub>x</sub> , C-O, and COO	Hydrocarbons not belonging to the MXene compound due to surface contamination and/or during washing
O(I) <sub>z</sub> -Ti-C	Oxygen surface termination bridging to Ti atoms belongs to the MXene structure
O(II) <sub>z</sub> -Ti-C	Oxygen surface termination occupying the FCC site belongs to the MXene structure
H <sub>2</sub> O <sub>ads</sub>	Adsorbed water on the MXene sheets

$(\text{F}, \text{O})_z\text{-Ti-C}$	MXene terminated by F surface group with the influence of other adsorbates or surface groups
LiF	Unwashed LiF compound present from the etching solution
$\text{Li}^+$	Li ions intercalated between the MXene sheets

**Table S4.** Gravimetric and volumetric capacitance for a  $\text{Ti}_3\text{C}_2\text{T}_z$  electrode.

Scan rate	Gravimetric capacitance, $\text{F g}^{-1}$	Volumetric capacitance, $\text{F cm}^{-3}$
2	174	470
5	156	420
10	147	398
20	141	381
50	133	359
100	126	340
200	118	320
500	106	286
1000	93	250

References:

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5. J. Halim, I. Persson, P. Eklund, P. O. Å. Persson, J. Rosen, Sodium Hydroxide and Vacuum Annealing Modifications of The Surface Terminations of a  $\text{Ti}_3\text{C}_2$  (Mxene) Epitaxial Thin Film. *RSC Adv.* **2018**, *8*, 36785-36790.